



Pulsed laser fabrication of TiO₂ buffer layers for dye sensitized solar cells

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Supplementary Materials:

1. Figure S1: Selected area electron diffraction (SAED) patterns for the mesoporous TiO₂ film (a), and the buffer layers: TO10 (b), TO50 (c), TAR10 (d), and TAR50 (e).

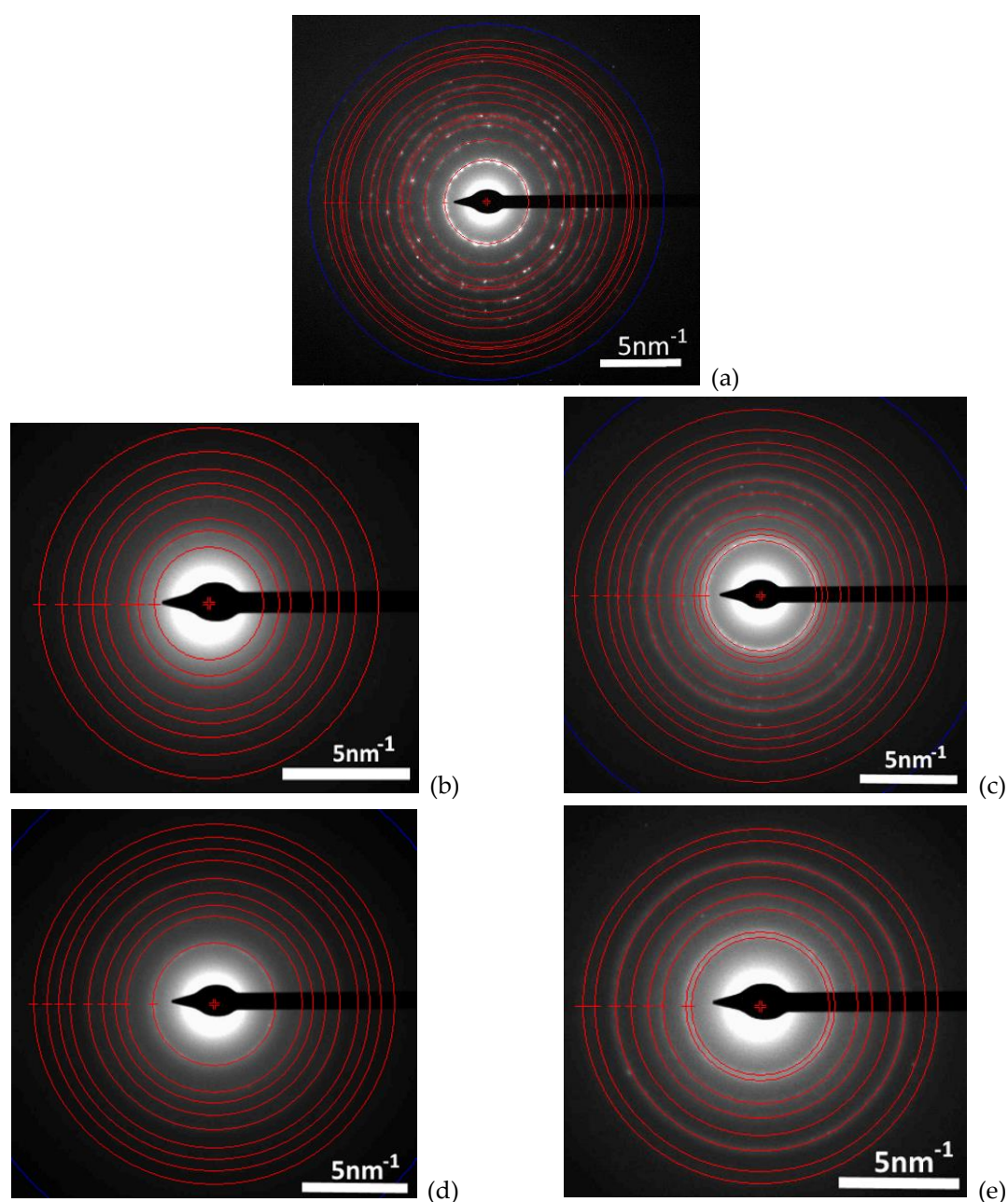


Figure S1. Selected area electron diffraction (SAED) patterns for the mesoporous TiO₂ film (a), and the buffer layers: TO10 (b), TO50 (c), TAR10 (d), and TAR50 (e).